

Symposium (Oral) | Symposium : Symposium on Research and Human-Capital Development Activities aimed at Creating Next-Generation Semiconductors Industry

🏛️ Fri. Mar 14, 2025 2:00 PM - 3:30 PM JST | Fri. Mar 14, 2025 5:00 AM - 6:30 AM UTC 🏛️ Y1311 (Bldg. 13)

[14p-Y1311-1~6] Symposium on Research and Human-Capital Development Activities aimed at Creating Next-Generation Semiconductors Industry

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2:30 PM - 2:45 PM JST | 5:30 AM - 5:45 AM UTC

[14p-Y1311-3] Ultra Short-TAT LSI Design and Fabrication Platform

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Keywords : LSI、 Design and Fabrication

One of the barriers to entry for semiconductor integrated circuits is the time required for design and prototyping. In this presentation, we will introduce the status of building a platform that enables design and prototyping of integrated circuits with ultra-short TAT.
